

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(use as many sheets as necessary)

Complete if Known

Application Number	Unknown 10/805,747
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Filing Date	Herewith
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Applicant(s)	Wu et al.
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Art Unit	Unknown
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Examiner Name	Unknown
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Attorney Docket Number	24061.200 (TSMC2003-1585)
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SHEET

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OF

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U. S. PATENT DOCUMENTS

[illegible]

FOREIGN PATENT DOCUMENTS

[illegible]

OTHER PRIOR ART

Examiner's Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article, title of the item, date, page(s), volume, issue number(s), publisher, city/country where published
AG		ALAVI, et al., A PROM Element Based on Salicide Agglomeration of Poly Fuses in a CMOS Logic Process, December 1997, 14 pgs., IEEE International Electron Device Meeting.
AM		MICHAEL WU, Electrical Fuse Structure for Low Voltage And Single Core Applications, December 16, 2003, 4 pgs., Taiwan Semiconductor Manufacturing Company, Ltd.

**Examiner
Signature**

Date
Considered

9/05

→ AG and AH references not considered because they are not in the PTO file.